HA-MFV DeviceNet[™]

High Accuracy Mass Flow Verifier

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The MKS High Accuracy MFV is designed for installation on the process tool to verify the mass flow controller flow rate in situ. The HA-MFV's 1.0% of Reading measurement accuracy gives the user the ability to verify the MFC's flow with the actual process gas to a degree significantly better than previous rate-of-rise devices or the process chamber rate-of-rise method. The former devices were subject to external volume effects while the latter method is subject to significant variation due to process chamber conditions.

The HA-MFV is able to provide significantly better measurement accuracy and is insensitive to external volume (volume from MFC to the HA-MFV) conditions and variation. This insensitivity of the HA-MFV to external volume also results in more precise matching of measurements between HA-MFVs on multiple tools for the same process. This assures the user of precise tool-to-tool process matching.

The insensitivity of the HA-MFV to external volume is realized through the use on sonic nozzle technology. The sonic nozzle creates a pressure drop and sonic flow conditions. In sonic flow, variations in pressure downstream of the nozzle have no effect on upstream conditions. Thus, the sonic nozzle effectively decouples the measurement in the HA-MFV from the upstream volume.

Product Features

- Superior 1.0% or better measurement accuracy enables wafer-to-wafer, chamber-to-chamber, and tool-to-tool process matching
- Ability to support multiple gas panels on a process tool due to its external volume insensitivity reduces cost of implementation
- Wide measurement range of 5 to 3000 sccm enables the measurement of most critical gas flow for a wide variety of semiconductor processes
- In situ assessment of MFC flow rate improves process control and avoids unnecessary down-time due to removal of a "good" MFC
- Rapid measurement times allows easy integration into tool preventative maintenance schedules



Key Benefits

- Direct process gas flow rate measurement to validate MFC accuracy
- Supports multiple gas panels on tool providing superior chamber to chamber flow matching

Mass Flow Verification Accuracy ¹	±1.0% Reading
Mass Flow Verification Range ²	5 to 3000 sccm N₂ equivalent
Repeatability	±0.5% Reading
Reproducibility	±0.3% Reading
Pressure Range	100 Torr
Pressure Accuracy	0.25% Reading
Proof Pressure	45 psia
Burst Pressure	150 psig
Pneumatic Air Supply Pressure Minimum Maximum	80 psig100 psig
Temperature Coefficients Span	<0.002% Reading/°C
Warm-up Time	60 minutes
Normal Operating Temperature	10° to 40°C
Temperature Display	0° to 100°C
Temperature Readout Units	°C
Temperature Accuracy	+2°C
Temperature Resolution	0.1°C
Compliance ²	CE
Environmental	
Storage Humidity Range	0 to 95% RH non-condensing
Storage Temperature	-20° to 60°C (-4° to 160°F)
Electrical/Communications	
Control Interface Options DeviceNet I/O	5-pin DeviceNet Micro Connector Type
Diagnostic Interface Options EtherNet	RJ-45 female
Input Voltage	11 to 25 VDC (DeviceNet)
Input Current/Voltage Required Max Current at Start Up Avg Current at Steady State	 +24 VDC (±5%) @ 500 mA +24 VDC (±5%) @ 375 mA (valves closed)
Physical	
Body Overall (height x width x length)	6.98 in x 10.0 in x 10.0 in (177.3 mm x 254.0 mm x 254.0 mm)
Process Connections Gas Supply Vacuum Supply Pneumatic Air Supply	 Swagelok[®] compatible 8 VCR[®] female rotatable Swagelok[®] compatible 8 VCR[®] female rotatable 1/8'' one-touch quick connect tube
Leak Integrity External	<1 x 10 ⁻⁹ scc/sec He
Materials Wetted Volume Seals Valve Seat	 316L SST passivated, Inconel[®], Incoloy[®] 316 SST nickel plated PCTFE with Elgiloy[®] Diaphragm
Surface Finish	<32 μ inches Ra

² Maximum flow rate may be limited by specific gas properties, e.g. vapor pressure.

Please consult factory for latest gas and flow rate list.

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HA-MFV Functional Block Diagram



The HA-MFV utilizes sonic nozzles to isolate upstream flow conditions from the device making it external volume insensitive. This insensitivity along with precise temperature, pressure and volume measurements enables the device to provide measurement accuracies of better than 1.0% of Reading.

Dimensional Drawing



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Unless otherwise specified, dimensions are nominal values in inches (mm referenced).

Ordering Information

Please contact your local MKS office for configuration and availability information.



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